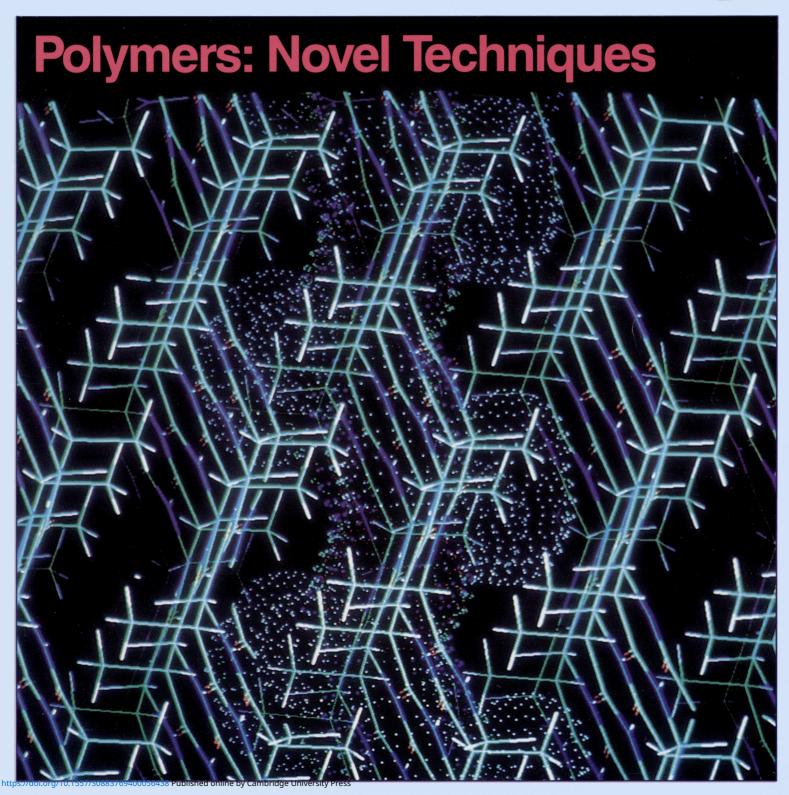
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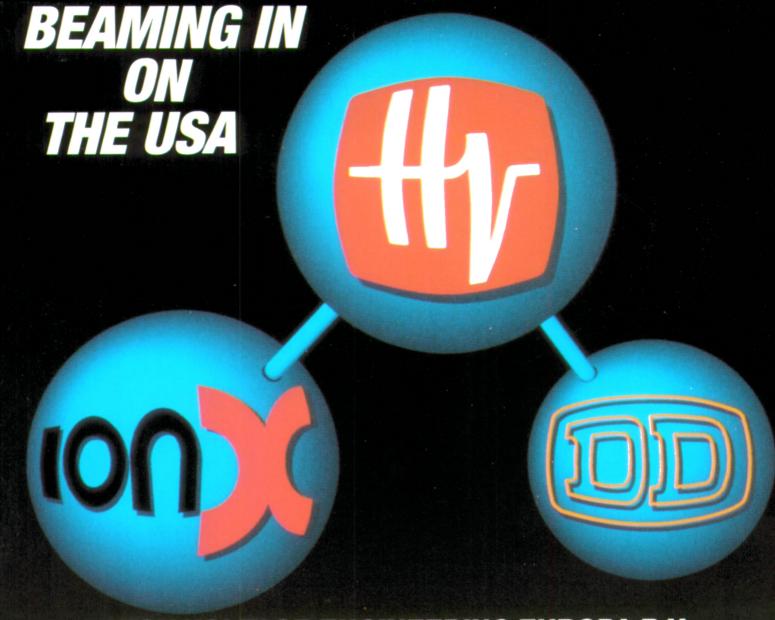
Serving the International Materials Research Community

A Publication of the Materials Research Society

July 1991, Volume XVI, No. 7







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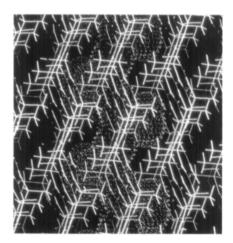
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ON THE COVER: Computer-generated image of stacked, folded β-sheets of an artificial periodic protein of sequence {{GlyAla}₃Gly-Glu}₃. The image was generated at the University of Massachusetts at Amherst on a Silicon Graphics Personal Iris Workstation running Biograf 2.1 software from Biodesign, Inc. Photo courtesy of E.D.T. Atkins, H.S. Creel, M.T. Krejchi, and F. Papadimitrakopoulos. See the articles beginning on p. 20 for more information about novel techniques for synthesizing and characterizing polymers.



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